The documentation and process conversion measures necessary to comply with this document shall be completed by 6 June 2020.

INCH-POUND
MIL-PRF-19500/727D
6 March 2020
SUPERSEDING
MIL-PRF-19500/727C
28 November 2014

PERFORMANCE SPECIFICATION SHEET

TRANSISTOR, NPN, SILICON, SWITCHING, DEVICE TYPES 2N5010 THROUGH 2N5015, JAN, JANTX, JANTXV, AND JANS

This specification is approved for use by all Departments and Agencies of the Department of Defense.

The requirements for acquiring the product described herein shall consist of this specification sheet and MIL-PRF-19500.

1. SCOPE

- 1.1 <u>Scope</u>. This specification covers the performance requirements for NPN, silicon, transistors. Four levels of product assurance are provided for each encapsulated device type as specified in MIL-PRF-19500.
- 1.2. <u>Package outlines</u>. The device package for this specification sheet is (TO-5 and TO-39) in accordance with figure 1 and (U4) in accordance with figure 2 for all packaged device types.
 - 1.3 Maximum ratings. Unless otherwise specified, $T_A = +25$ °C.

Types	Ic	Ι _Β	V_{CBO}	V_{CER}	V_{EBO}	T _J and T _{STG} (1)
	mA dc	mA dc	V dc	V dc	<u>V dc</u>	<u>°С</u>
2N5010, 2N5010S, U4	200	20	500	500	5	-65 to +200
2N5011, 2N5011S, U4	200	20	600	600	5	-65 to +200
2N5012, 2N5012S, U4	200	20	700	700	5	-65 to +200
2N5013, 2N5013S, U4	200	20	800	800	5	-65 to +200
2N5014, 2N5014S, U4	200	20	900	900	5	-65 to +200
2N5015, 2N5015S, U4	200	20	1000	1000	5	-65 to +200

	P _T	P _T		
Types	$T_A = +25^{\circ}C$ (2) (3)	$T_C = +25^{\circ}C$ (2) (3)	R _{θJA} (3) (4)	R _{θJC} (3) (4)
	<u>W</u>	<u>W</u>	°C/W	°C/W
2N5010 through 2N5015 and 2N5010S through 2N5015S	1	7	175	20
2N5010U4 through 2N5015U4	1	7	175	7

- (1) For derating, see figures 3, 4, and 5.
- (2) See figure 5 for special bias considerations under ambient operation.
- (3) For thermal impedance curves, see figures 6, 7, 8, and 9.
- (4) $T_A = 25^{\circ}\text{C}$ for (U4) on printed circuit board (PCB), PCB = FR4 .0625 inch (1.59 mm) 1-layer 1-Oz Cu, horizontal, still air, pads (U4) = .067 x .065 inch (1.7 x 1.65 mm) for the two smaller pads and .165 x .135 inch (4.19 x 3.43 mm) for the larger collector pad; $R_{\theta JA}$ with a defined PCB thermal resistance condition included.

Comments, suggestions, or questions on this document should be addressed to DLA Land and Maritime, ATTN: VAC, P.O. Box 3990, Columbus, OH 43218–3990, or emailed to semiconductor@dla.mil. Since contact information can change, you may want to verify the currency of this address information using the ASSIST Online database at https://assist.dla.mil.

AMSC N/A FSC 5961

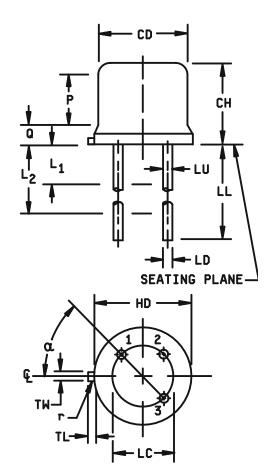


1.4 Primary electrical characteristics at T_A = +25°C. Unless otherwise specified, T_A = +25°C.

Types	h _{FE} at V _{CE} = 10 V dc		$V_{CE(sat)1}$ (1) $I_{C} = 25 \text{ mA}$ dc	$V_{BE(sat)1}$ (1) $I_{C} = 25 \text{ mA}$ dc	/h _{fe} / f = 10 MHz	$\begin{array}{c} C_{\text{obo}} \\ 100 \text{ kHz} \leq f \leq 2 \\ \text{MHz} \end{array}$		
	$I_C = 2$	h_{FE1} $I_C = 25 \text{ mA}$ dc		_{FE2} 5 mA dc	$I_B = 5 \text{ mA dc}$	$I_B = 5 \text{ mA dc}$	V_{CE} = 10 V dc I_{C} = 25 mA dc	$V_{CB} = 10 \text{ V dc}$ $I_E = 0$
	min	max	min	max	<u>V dc</u>	<u>V dc</u>		<u>pF</u>
2N5010, 2N5010S U4	30	180	10		1.4	1	1	30
2N5011, 2N5011S, U4	30 180		180 10 1.5	1.5	1	1	30	
2N5012, 2N5012S, U4	30	180	10		1.6	1	1	30
Types	h _{FE} at V _{CE}		= 10 V	dc	$V_{CE(sat)1}$ (1) $I_C = 20 \text{ mA}$ dc	$V_{BE(sat)1}$ (1) $I_C = 20 \text{ mA}$ dc	/h _{fe} / f = 10 MHz	$\begin{array}{c} C_{obo} \\ 100 \text{ kHz} \leq f \leq 2 \\ \text{MHz} \end{array}$
	h_{FE1} $I_C = 20 \text{ mA}$				$I_B = 5 \text{ mA dc}$	$I_B = 5 \text{ mA dc}$	$V_{CE} = 10 \text{ V dc}$ $I_{C} = 20 \text{ mA dc}$	V _{CB} = 10 V dc I _E = 0
	min	max	min	max	V dc	V dc		pF
2N5013, 2N5013S U4	30	180	10		1.6	1	1	30
2N5014, 2N5014S, U4	30	180	10		1.6	1	1	30
2N5015, 2N5015S, U4	30	180	10		1.8	1	1	30

⁽¹⁾ Pulsed see 4.5.1.

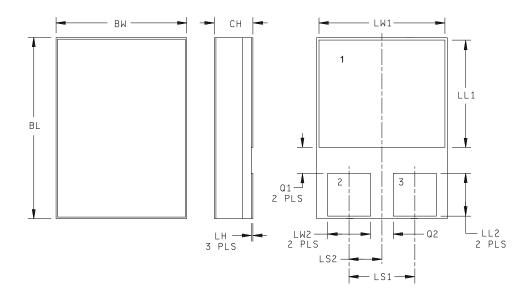
Symbol	Incl	nes	Millin	Note			
	Min	Max	Min	Max			
CD	.305	.335	7.75	8.51	6		
CH	.240	.260	6.10	6.60			
HD	.335	.370	8.51	9.40			
LC	.200	TP	5.0	8 TP	7		
LD	.016	.019	0.41	0.48	8,9		
LL		S	ee note				
LU	.016	.019	0.41	0.48	8,9		
L ₁		.050		1.27	8,9		
L ₂	.250		6.35		8,9		
Р	.100		2.54		7		
Q		.030		0.76	5		
TL	.029	.045	0.74	1.14	3,4		
TW	.028	.034	0.71	0.86	3		
r		.010		0.25	11		
α	45°	TP	45° TP		7		
	1, 2, 10, 12, 13, 14						



NOTES:

- 1. Dimensions are in inches.
- 2. Millimeters are given for general information only.
- 3. Beyond r (radius) maximum, TW shall be held for a minimum length of .011 (0.28 mm).
- 4. Dimension TL measured from maximum HD.
- 5. Body contour optional within zone defined by HD, CD, and Q.
- 6. CD shall not vary more than .010 inch (0.25 mm) in zone P. This zone is controlled for automatic handling.
- 7. Leads at gauge plane .054 +.001 -.000 inch (1.37 +0.03 -0.00 mm) below seating plane shall be within .007 inch (0.18 mm) radius of true position (TP) at maximum material condition (MMC) relative to tab at MMC. The device may be measured by direct methods or by gauging procedure.
- 8. Dimension LU applies between L₁ and L₂. Dimension LD applies between L₂ and LL minimum. Diameter is uncontrolled in L₁ and beyond LL minimum.
- 9. All three leads.
- 10. The collector shall be internally connected to the case.
- 11. Dimension r (radius) applies to both inside corners of tab.
- 12. In accordance with ASME Y14.5M, diameters are equivalent to Φx symbology.
- 13. Lead 1 = emitter, lead 2 = base, lead 3 = collector.
- 14. For non-S-suffix devices (TO-5), dimension LL = 1.5 inches (38.10 mm) min. and 1.75 inches (44.45 mm) max. For S-suffix types (TO-39), dimension LL = .5 inch (12.70 mm) min. and .750 inch (19.05 mm) max.

FIGURE 1. Physical dimensions (TO-5 and TO-39).



Symbol		Dimensions				
	Incl	hes	Milli	meters		
	Min	Max	Min	Max		
BL	.215	.225	5.46	5.72		
BW	.145	.155	3.68	3.94		
CH	.049	.075	1.24	1.91		
LH		.02		0.51		
LW1	.135	.145	3.43	3.68		
LW2	.047	.057	1.19	1.45		
LL1	.085	.125	2.16	3.17		
LL2	.045	.075	1.14	1.9		
LS1	.070	.095	1.78	2.41		
LS2	.035	.048	0.89	1.21		
Q1	.03	.070	0.76	1.78		
Q2	.02	.035	0.51	0.89		
TERM 1		Colle	ector			
TERM 2	Base					
TERM 3		Emi	tter			

NOTES:

- 1. Dimensions are in inches.
- 2. Millimeter equivalents are given for general information only.
- 3. In accordance with ASME Y14.5M, diameters are equivalent to $\emptyset x$ symbology.

FIGURE 2. Physical dimensions, surface mount (U4 version).

- 1.5 <u>Part or Identifying Number (PIN)</u>. The PIN is in accordance with MIL-PRF-19500, and as specified herein. See 6.4 for PIN construction example and 6.5 for a list of available PINs.
- 1.5.1 <u>JAN brand and quality level</u>. The quality level designators for encapsulated devices that are applicable for this specification sheet from the lowest to the highest level are as follows: The base quality level "JAN" that uses no modifiers, "TX", "TXV" and "S".
- 1.5.2 <u>Device type</u>. The designation system for the device types of transistors covered by this specification sheet are as follows.
- 1.5.2.1 <u>First number and first letter symbols</u>. The transistors of this specification sheet are identified by the first number and letter symbols "2N".
- 1.5.2.2 <u>Second number symbols</u>. The second number symbols for the transistors covered by this specification sheet are as follows: "5010" through "5015".
 - 1.5.3 Suffix letters. The following suffix letters are incorporated in the PIN for this specification sheet:

	Blank suffix indicates a TO-5 package. (see figure 1)
S	Indicates a package similar to a TO-39 (see figure 1).
U4	Indicates a 3 pad surface mount package (see figure 2).

^{* 1.5.4} Lead finish. The lead finishes applicable to this specification sheet are listed on QML-19500.

2. APPLICABLE DOCUMENTS

2.1 <u>General</u>. The documents listed in this section are specified in sections 3, and 4 of this specification. This section does not include documents cited in other sections of this specification or recommended for additional information or as examples. While every effort has been made to ensure the completeness of this list, document users are cautioned that they must meet all specified requirements of documents cited in sections 3, and 4 of this specification, whether or not they are listed.

2.2 Government documents.

2.2.1 <u>Specifications, standards, and handbooks</u>. The following specifications, standards, and handbooks form a part of this document to the extent specified herein. Unless otherwise specified, the issues of these documents are those cited in the solicitation or contract.

DEPARTMENT OF DEFENSE SPECIFICATIONS

MIL-PRF-19500 - Semiconductor Devices, General Specification for.

DEPARTMENT OF DEFENSE STANDARDS

MIL-STD-750 - Test Methods for Semiconductor Devices.

(Copies of these documents are available online at https://quicksearch.dla.mil.)

2.3 <u>Order of precedence</u> Unless otherwise noted herein or in the contract, in the event of a conflict between the text of this document and the references cited herein, the text of this document takes precedence. Nothing in this document, however, supersedes applicable laws and regulations unless a specific exemption has been obtained.

- 3. REQUIREMENTS
- 3.1 General. The individual item requirements shall be as specified in MIL-PRF-19500 and as modified herein.
- 3.2 Qualification. Devices furnished under this specification shall be products that are manufactured by a manufacturer authorized by the qualifying activity for listing on the applicable qualified manufacturers list before contract award (see 4.2 and 6.3).
- 3.3 <u>Abbreviations, symbols, and definitions</u>. Abbreviations, symbols, and definitions used herein shall be as specified in MIL-PRF-19500.
- 3.4 <u>Interface and physical dimensions</u>. The interface requirements and physical dimensions shall be as specified in <u>MIL-PRF-19500</u> and herein. The device package style is either a TO-5, TO-39 or U4 in accordance with figure 1 and figure 2 for all device types.
- 3.4.1 <u>Lead finish</u>. Unless otherwise specified, lead finish shall be solderable in accordance with MIL-PRF-19500, MIL-STD-750, and herein. Where a choice of lead finish is desired, it shall be specified in the acquisition document (see 6.2).
 - 3.4.2 Pin-out. The pin-out of the device shall be as shown on figure 1 and figure 2.
- 3.5 <u>Electrical performance characteristics</u>. Unless otherwise specified herein, the electrical performance characteristics are as specified in paragraph 1.2.2, 1.2.3, and table I.
 - 3.6 Marking. Marking shall be in accordance with MIL-PRF-19500.
- 3.7 <u>Workmanship</u>. Transistors shall be processed in such a manner as to be uniform in quality and shall be free from other defects that will affect life, serviceability, or appearance.
 - 4. VERIFICATION
 - 4.1 <u>Classification of inspections</u>. The inspection requirements specified herein are classified as follows:
 - a. Qualification inspection (see 4.2).
 - b. Screening (see 4.3).
 - c. Conformance inspection (see 4.4 and tables I and II).
- 4.2 <u>Qualification inspection</u>. Qualification inspection shall be in accordance with MIL-PRF-19500 and as specified herein.
- 4.2.1 <u>Group E qualification</u>. Group E inspection shall be performed for qualification or re-qualification only. In case qualification was awarded to a prior revision of the specification sheet that did not request the performance of table II tests, the tests specified in table II herein that were not performed in the prior revision shall be performed on the first inspection lot of this revision to maintain qualification.

* 4.3 <u>Screening (JANS, JANTX, and JANTXV levels only)</u>. Screening shall be in accordance with table E-IV <u>MIL-PRF-19500</u>, and as specified herein. The following measurements shall be made in accordance with table I herein. Devices that exceed the limits of table I herein shall not be acceptable.

Screen		Measurement			
	JANS level	JANTX and JANTXV levels			
2	Optional	Optional			
3a	Required	Required			
3b	Not applicable	Not applicable			
3c	Thermal impedance (transient), method 3131 of MIL-STD-750 (1)	Thermal impedance (transient), method 3131 of MIL-STD-750 (1)			
4	Required	Optional			
5	Required	Not applicable			
8	Required	Not required			
9	I _{CBO1} , h _{FE1}	Not applicable			
10	48 hours minimum	48 hours minimum			
11	I_{CBO1} ; h_{FE1} ; $\Delta I_{CBO1} = 100$ percent of initial value or 5 nA dc, whichever is greater. $\Delta h_{FE1} = \pm 15$ percent	I _{CBO1} ; h _{FE1}			
12	See 4.3.1	See 4.3.1			
13	Subgroups 2 and 3 of table I herein; $\Delta I_{CBO1} = 100$ percent of initial value or 5 nA dc, whichever is greater; $\Delta h_{FE1} = \pm 15$ percent	Subgroup 2 of table I herein; ΔI_{CBO1} = 100 percent of initial value or 5 nA dc, whichever is greater; Δh_{FE1} = ±15 percent			
15	Required	Not required			
16	Required	Not required			

⁽¹⁾ Shall be performed any time after temperature cycling, screen 3a; and does not need to be repeated in screening requirements.

^{4.3.1 &}lt;u>Power burn-in conditions</u>. Power burn-in conditions are as follows: $V_{CB} = 10 - 30 \text{ V}$ dc. Power shall be applied to achieve $T_J = +135^{\circ}\text{C}$ minimum using a minimum $P_D = 75$ percent of P_T maximum, rated as defined in 1.3. With approval of the qualifying activity and preparing activity, alternate burn-in criteria (hours, bias conditions, T_J , mounting conditions) may be used for JANTX and JANTXV quality levels. A justification demonstrating equivalence is required. In addition, the manufacturing site's burn-in data and performance history will be essential criteria for burn-in modification approval. Use method 3100 of MIL-STD-750 to measure T_J .

- * 4.3.2 <u>Thermal impedance</u>. The thermal impedance measurements shall be performed in accordance with method 3131 of MIL-STD-750 using the guidelines in that method for determining I_M, I_H, t_{MD}, and t_{SW} (V_C and V_H where appropriate). See table II, group E, subgroup 4 herein.
- 4.4 <u>Conformance inspection</u>. Conformance inspection shall be in accordance with MIL-PRF-19500, and as specified herein. If alternate screening is being performed in accordance with MIL-PRF-19500, a sample of screened devices shall be submitted to and pass the requirements of group A1 and A2 inspection only (table E-Vlb, group B, subgroup 1 is not required to be performed again if group B has already been satisfied in accordance with 4.4.2).
- 4.4.1 <u>Group A inspection</u>. Group A inspection shall be conducted in accordance with MIL-PRF-19500, and table I herein.
- 4.4.2 <u>Group B inspection</u>. Group B inspection shall be conducted in accordance with the tests and conditions specified for subgroup testing in table E-VIa (JANS) of MIL-PRF-19500 and 4.4.2.1. See 4.4.2.2 for JAN, JANTX, and JANTXV group B testing.
 - 4.4.2.1 Group B inspection (JANS), table E-VIa of MIL-PRF-19500.

Subgroup	Method	Condition
B4	1037	$V_{CB} \ge 10 \text{ V dc.}$
B5	1027	V_{CB} = 10 V dc; $P_D \ge$ 100 percent of maximum rated P_T (see 1.3). (NOTE: If a failure occurs, resubmission shall be at the test conditions of the original sample.)
		Option 1: 96 hours minimum sample size in accordance with table E-Via of MIL-PRF-19500, adjust T_A or P_D to achieve T_J = +275°C minimum.
		Option 2: 216 hours minimum, sample size = 45, c = 0; adjust T_A or P_D to achieve a T_J = +225°C minimum.

4.4.2.2 <u>Group B inspection</u>, (JAN, JANTX, and JANTXV). Separate samples may be used for each step. In the event of a lot failure, the resubmission requirements of <u>MIL-PRF-19500</u> shall apply. In addition, all catastrophic failures during CI shall be analyzed to the extent possible to identify root cause and corrective action. Whenever a failure is identified as wafer lot or wafer processing related, the entire wafer lot and related devices assembled from the wafer lot shall be rejected unless an appropriate determined corrective action to eliminate the failure mode has been implemented and the devices from the wafer lot are screened to eliminate the failure mode.

<u>Step</u>	Method	Condition
1	1026	Steady-state life: 1,000 hours minimum, V_{CB} = 10 V dc, power shall be applied to achieve T_J = +150°C minimum using a minimum of P_D = 75 percent of maximum rated P_T as defined in 1.3. n = 45 devices, c = 0.
2	1048	Blocking life: T_A = +150°C, V_{CB} = 80 percent rated voltage, 48 hours minimum. n = 45 devices, c = 0.
3	1032	High-temperature life (non-operating), $t = 340$ hours, $T_A = +200$ °C. $n = 22$, $c = 0$.

- 4.4.2.3 <u>Group B sample selection</u>. Samples selected from group B inspection shall meet all of the following requirements:
 - For JAN, JANTX, and JANTXV samples shall be selected randomly from a minimum of three wafers (or from each wafer in the lot) from each wafer lot. For JANS, samples shall be selected from each inspection lot. See MIL-PRF-19500.
 - b. Shall be chosen from an inspection lot that has been submitted to and passed table I, subgroup 2, conformance inspection. When the final lead finish is solder or any plating prone to oxidation at high temperature, the samples for life test (subgroups B4 and B5 for JANS, and group B for JAN, JANTX, and JANTXV) may be pulled prior to the application of final lead finish.
- 4.4.3 <u>Group C inspection</u>, Group C inspection shall be conducted in accordance with the test and conditions specified for subgroup testing in table E-VII of MIL-PRF-19500, and in 4.4.3.1 (JANS) and 4.4.3.2 (JAN, JANTX, and JANTXV) herein for group C testing.
 - 4.4.3.1 Group C inspection (JANS), table E-VII of MIL-PRF-19500.

Subgroup	Method	Condition
C2	2036	Test condition E; not applicable for U4 devices.
C5	3131	$R_{\theta JA}$ and $R_{\theta JC}$ only, as applicable (see 1.3).
C6	1026	1,000 hours at V_{CB} = 10 V dc; power shall be applied to achieve T_J = +150°C minimum and a minimum of P_D = 75 percent of maximum rated P_T as defined in 1.3, n = 45, c = 0.

4.4.3.2 Group C inspection (JAN, JANTX, and JANTXV), table E-VII of MIL-PRF-19500.

<u>Subgroup</u>	<u>Method</u>	Condition
C2	2036	Test condition E; not applicable for U4 devices.
C5	3131	$R_{\theta JA}$ and $R_{\theta JC}$ only, as applicable (see 1.3).
C6		Not applicable.

- 4.4.3.3 <u>Group C sample selection</u>. Samples for subgroups in group C shall be chosen at random from any inspection lot containing the intended package type and lead finish procured to the same specification which is submitted to and passes table I tests herein for conformance inspection. When the final lead finish is solder or any plating prone to oxidation at high temperature, the samples for C6 life test may be pulled prior to the application of final lead finish. Testing of a subgroup using a single device type enclosed in the intended package type shall be considered as complying with the requirements for that subgroup.
- 4.4.4 <u>Group E inspection</u>. Group E inspection shall be conducted in accordance with the conditions specified for subgroup testing in table E-IX of MIL-PRF-19500 and as specified in table II herein.
 - 4.5 <u>Method of inspection</u>. Methods of inspection shall be as specified in the appropriate tables and as follows.
 - 4.5.1 Pulse measurements. Conditions for pulse measurement shall be as specified in section 4 of MIL-STD-750.

* TABLE I. Group A inspection.

Inspection 1/		MIL-STD-750		Lir	Unit	
	Method	Conditions	Symbol	Min	Max	
Subgroup 1 2/						
Visual and mechanical examination 3/	2071					
Solderability <u>3</u> / <u>4</u> /	2026	n = 15 leads, c = 0				
Resistance to solvents 3/ 4/ 5/	1022	n = 15 devices, c = 0				
Temp cycling 3/4/	1051	Test condition C, 25 cycles. n = 22 devices, c = 0				
Hermetic seal <u>4</u> / <u>6</u> / Fine leak Gross leak	1071	n = 22 devices, c = 0				
Electrical measurements 4/		Table I, subgroup 2				
Bond strength <u>3</u> / <u>4</u> /	2037	Precondition $T_A = +250^{\circ}\text{C}$ at t = 24 hrs or $T_A = +300^{\circ}\text{C}$ at t = 2 hrs $n = 11$ wires, $c = 0$				
Decap internal visual (design verification) 4/	2075	n = 4 devices, c = 0				
Subgroup 2						
Thermal impedance 7/	3131	See 4.3.2	$Z_{\theta JX}$			°C/W
Collector to base cutoff current	3036	Condition D	I _{CBO1}			nA dc
2N5010, 2N5010S, U4 2N5011, 2N5011S, U4		$V_{CB} = 400 \text{ V dc}$ $V_{CB} = 500 \text{ V dc}$			10 10	
2N5011, 2N50113, 04 2N5012, 2N5012S, U4		$V_{CB} = 580 \text{ V dc}$			10	
2N5013, 2N5013S, U4		$V_{CB} = 650 \text{ V dc}$			10	
2N5014, 2N5014S, U4 2N5015, 2N5015S, U4		$V_{CB} = 700 \text{ V dc}$ $V_{CB} = 760 \text{ V dc}$			10 10	
Emitter to base cutoff current	3061	Condition D, V _{EB} = 4 V dc	I _{EBO1}		20	μ A dc
Breakdown voltage, collector to		I _E = 0 mA dc	$V_{(BR)CB}$			V dc
base 2N5010, 2N5010S, U4 2N5011, 2N5011S, U4 2N5012, 2N5012S, U4 2N5013, 2N5013S, U4 2N5014, 2N5014S, U4 2N5015, 2N5015S, U4		$\begin{split} I_C &= 0.1 \text{ mA dc} \\ I_C &= 0.1 \text{ mA dc} \\ I_C &= 0.1 \text{ mA dc} \\ I_C &= 0.2 \text{ mA dc} \\ \end{split}$	0	500 600 700 800 900 1,000		
Breakdown voltage, emitter to base		$I_{\rm C}$ = 0 mA dc, $I_{\rm E}$ = 0.05 mA dc	V _{(BR)EBO}	5		V dc

See footnotes at end of table.

* TABLE I. Group A inspection - Continued.

Inspection 1/ MIL		MIL-STD-750		Limit		Unit
	Method	Conditions	Symbol	Min	Max	
Subgroup 2 - Continued						
Breakdown voltage, collector to emitter	3011	Bias condition B; $R_{BE} = 1K\Omega$ $I_{C} = 0.2$ mA dc pulsed (see 4.5.1)	V _{(BR)CER}			V dc
2N5010, 2N5010S, U4		4.5.1)		500		
2N5011, 2N5011S, U4				600		
2N5012, 2N5012S, U4				700		
2N5013, 2N5013S, U4				800		
2N5014, 2N5014S, U4				900		
2N5015, 2N5015S, U4				1,000		
Forward-current transfer ratio	3076		h _{FE1}			
2N5010, 2N5011, 2N5012 2N5010S, 2N5010U4, 2N5011S, 2N5011U4, 2N5012S, 2N5012U4		$V_{CE} = 10 \text{ V dc}; I_{C} = 25 \text{ mA dc}$		30	180	
2N5012S, 2N5012U4 2N5013, 2N5014, 2N5015 2N5013S, 2N5014U4, 2N5015S, 2N5013U4, 2N5014S, 2N5015U4		V_{CE} = 10 V dc; I_C = 20 mA dc		30	180	
Forward-current transfer ratio	3076	$V_{CE} = 10 \text{ V dc}; I_{C} = 5 \text{ mA dc}$	h _{FE2}	10		
Base-emitter saturation voltage	3066	Test condition A; I _B = 5 mA dc; pulsed (see 4.5.1)	V _{BE(sat)1}			
2N5010, 2N5010S, U4		$I_C = 25 \text{ mA dc}$			1	V dc
2N5011, 2N5011S, U4		I _C = 25 mA dc			1	V dc
2N5012, 2N5012S, U4 2N5013, 2N5013S, U4		$I_C = 25 \text{ mA dc}$ $I_C = 20 \text{ mA dc}$			1	V dc V dc
2N5014, 2N5014S, U4		$I_C = 20 \text{ mA dc}$			1	V dc
2N5015, 2N5015S, U4		I _C = 20 mA dc			1	V dc
Collector-emitter saturation voltage	3071	I _B = 5 mA dc; pulsed (see	V _{CE(sat)1}			
2N5010, 2N5010S, U4		$I_C = 25 \text{ mA dc}$			1.4	V dc
2N5011, 2N5011S, U4		I _C = 25 mA dc			1.5	V dc
2N5012, 2N5012S, U4 2N5013, 2N5013S, U4		$I_{C} = 25 \text{ mA dc}$ $I_{C} = 20 \text{ mA dc}$			1.6 1.6	V dc V dc
2N5014, 2N5014S, U4		I _C = 20 mA dc			1.6	V dc
2N5015, 2N5015S, U4		$I_C = 20 \text{ mA dc}$			1.8	V dc

See footnotes at end of table.

* TABLE I. Group A inspection - Continued.

Inspection 1/	MIL-STD-750			Limit		Unit
	Method	Conditions	Symbol	Min	Max	
Subgroup 3 - Continued						
High temperature operation		T _A = +150°C				
Collector to base cutoff current 2N5010, 2N5010S, U4 2N5011, 2N5011S, U4 2N5012, 2N5012S, U4 2N5013, 2N5013S, U4 2N5014, 2N5014S, U4 2N5015, 2N5015S, U4	3036	Bias condition D; $V_{CB} = 400 \text{ V dc}$ $V_{CB} = 500 \text{ V dc}$ $V_{CB} = 588 \text{ V dc}$ $V_{CB} = 650 \text{ V dc}$ $V_{CB} = 700 \text{ V dc}$ $V_{CB} = 760 \text{ V dc}$	I _{CBO2}		10 10 10 10 10 10	μA dc
		V _{CB} = 760 V dC			10	
Low temperature operation Forward-current transfer ratio	3076	$T_A = -55^{\circ}C$ $V_{CE} = 10 \text{ V dc}; I_C = 20 \text{ mA dc}$	h _{FE3}	10		
Subgroup 4						
Magnitude of small-signal short-circuit forward current transfer ratio 2N5010, 2N5011, 2N5012 2N5010S, 2N5010U4, 2N5011S, 2N5011U4, 2N5012S, 2N5012U4	3306	$V_{CE} = 10 \text{ V dc}$; $I_{C} = 25 \text{ mA dc}$; $f = 10 \text{ MHz}$	/h _{fe} /	1		
Magnitude of small-signal short-circuit forward current transfer ratio 2N5013, 2N5014, 2N5015 2N5013S, 2N5014S, 2N5015S, 2N5013U4, 2N5014U4, 2N5015U4	3306	V_{CE} = 10 V dc; I_{C} = 20 mA dc; f = 10 MHz	/h _{fe} /	1		
Open circuit output capacitance Subgroups 5 and 6 Not required	3236	$V_{CB} = 10 \text{ V dc}; I_E = 0; f = 2 \text{ MHz}$	C _{obo}		30	pF

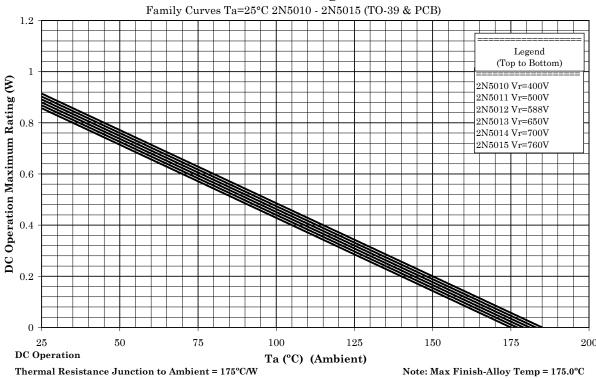
- 1/ For sampling plan see MIL-PRF-19500.
- 2/ For resubmission of failed table I, subgroup 1, double the sample size of the failed test or sequence of tests.

 A failure in table I, subgroup 1 shall not require retest of the entire subgroup. Only the failed test shall be rerun upon submission.
- 3/ Separate samples may be used.
- 4/ Not required for JANS devices.
- 5/ Not required for laser marked devices.
- 6/ This hermetic seal test is an end-point to temp cycling in addition to electrical measurements.
- 7/ For end-point measurements, this test is required for the following subgroups:
 - Group B, subgroups 3, 4 and 5 (JANS).
 - Group B, subgroups 2 and 3 (JAN, JANTX, JANTXV).
 - Group C, subgroups 2 and 6.
 - Group E, subgroup 1.

TABLE II. Group E inspection (all quality levels) - for qualification or re-qualification only.

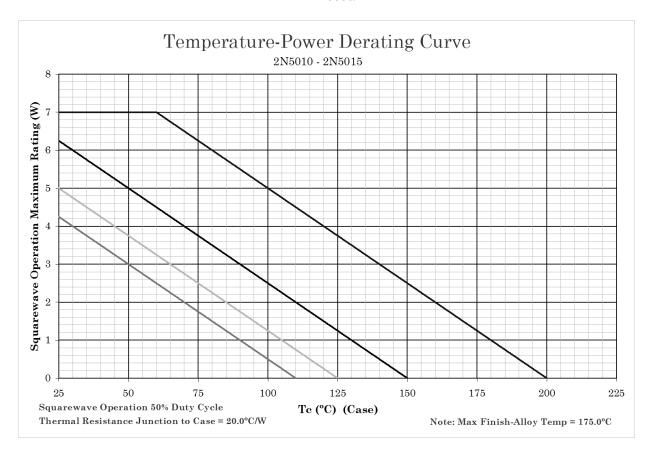
Inspection	MIL-STD-750		Qualificatio	
Inspection	Method	Conditions	n	
Subgroup 1			45 devices c = 0	
Temperature cycling (air to air)	1051	Test condition C, 500 cycles.		
Hermetic seal	1071			
Fine leak Gross leak				
Electrical measurements		See table I, subgroup 2.		
Subgroup 2			45 devices c = 0	
Intermittent life	1037	Intermittent operation life: V_{CB} = 10 V dc, 6,000 cycles. Adjust device current, or power, to achieve a minimum ΔT_J of +100°C.		
Electrical measurements		See table I, subgroup 2.		
Subgroup 4				
Thermal impedance curves		See MIL-PRF-19500.		
Subgroup 5			15 devices	
Barometric pressure	1001	I _C = 0.1 mA, condition D, pressure = 8 mm HG, normal mounting, t = 60 seconds minimum.	c = 0	
Subgroup 6				
ESD	1020			
Subgroup 8			45 devices c = 0	
Reverse stability	1033	Condition A.	_	

Ambient Derating Curves



NOTE: Applies only to ambient (free air) operation either asTO-5, TO-39, or as U4 on a PCB (dc operation).

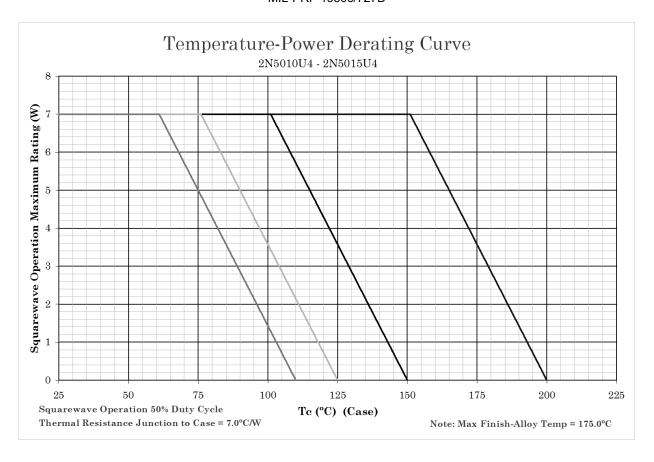
FIGURE 3. Ambient temperature-power derating curve.



NOTES:

- This is the true inverse of the worst case thermal resistance value. All devices are capable of operating at ≤ T_J specified on this curve. Any parallel line to this curve will intersect the appropriate power for the desired maximum T_J allowed.
- 2. Derate design curve constrained by the maximum junction temperature ($T_J \le 200^{\circ}C$) and power rating specified. (See 1.3 herein.)
- 3. Derate design curve chosen at $T_J \le 150^{\circ}C$, where the maximum temperature of electrical test is performed.
- 4. Derate design curves chosen at $T_J \le$, 125°C, and 110°C to show power rating where most users want to limit T_J in their application.

FIGURE 4. Temperature-power derating for steel (TO-5 and TO-39).



NOTES:

- 1. This is the true inverse of the worst case thermal resistance value. All devices are capable of operating at $\leq T_J$ specified on this curve. Any parallel line to this curve will intersect the appropriate power for the desired maximum T_J allowed.
- 2. Derate design curve constrained by the maximum junction temperature ($T_J \le 200^{\circ}C$) and power rating specified. (See 1.3 herein.)
- 3. Derate design curve chosen at $T_J \le 150^{\circ}C$, where the maximum temperature of electrical test is performed.
- 4. Derate design curves chosen at $T_J \le$, 125°C, and 110°C to show power rating where most users want to limit T_J in their application.

FIGURE 5. Temperature-power derating for (U4).

Maximum Thermal Impedance

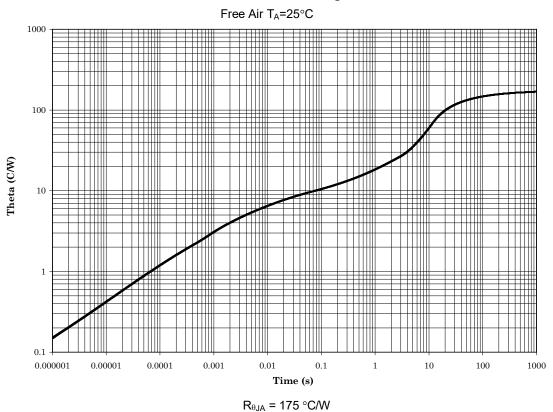
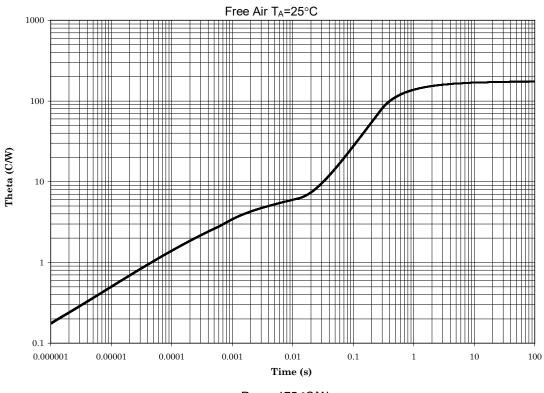


FIGURE 6. Thermal impedance graph for 2N5010 through 2N5015 steel (TO-5 and TO-39).

Maximum Thermal Impedance

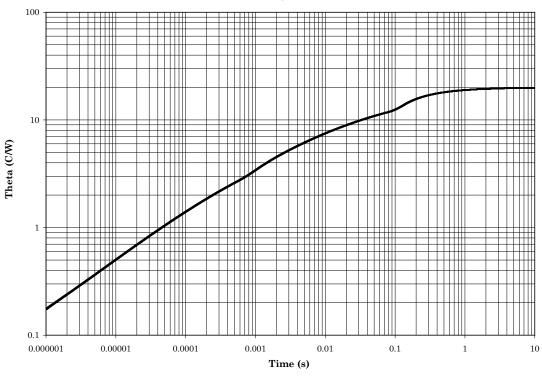


 $R_{\theta JA}$ = 175 °C/W

FIGURE 7. Thermal impedance graph for 2N5010U4 through 2N5015U4.

Maximum Thermal Impedance

Case Mount T_C=25°C

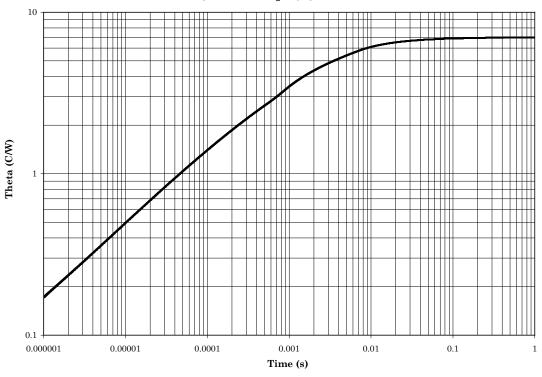


 $R_{\theta JC}$ = 20 °C/W

FIGURE 8. Thermal impedance graph for 2N5010 through 2N5015, steel (TO-5 and TO-39).

Maximum Thermal Impedance

Case Mount T_C=25°C



 $R_{\theta JC}$ = 7 °C/W

FIGURE 9. Thermal impedance graph for 2N5010U4 through 2N5015U4.

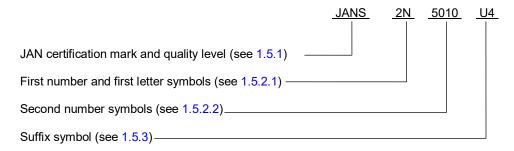
5. PACKAGING

5.1 <u>Packaging</u>. For acquisition purposes, the packaging requirements shall be as specified in the contract or order (see 6.2). When packaging of materiel is to be performed by DoD or in-house contractor personnel, these personnel need to contact the responsible packaging activity to ascertain packaging requirements. Packaging requirements are maintained by the Inventory Control Points' packaging activity within the Military Service or Defense Agency, or within the Military Service's system commands. Packaging data retrieval is available from the managing Military Department's or Defense Agency's automated packaging files, CD-ROM products, or by contacting the responsible packaging activity.

6. NOTES

(This section contains information of a general or explanatory nature that may be helpful, but is not mandatory. The notes specified in MIL-PRF-19500 are applicable to this specification.)

- 6.1 <u>Intended use</u>. Semiconductors conforming to this specification are intended for original equipment design applications and logistic support of existing equipment.
 - 6.2 <u>Acquisition requirements.</u> Acquisition documents should specify the following:
 - a. Title, number, and date of this specification.
 - b. Packaging requirements (see 5.1).
 - c. Lead finish (see 3.4.1).
 - d. The complete Part or Identifying Number (PIN), see title and section 1.
 - e. Surface mount designation if applicable.
- 6.3 <u>Qualification</u>. With respect to products requiring qualification, awards will be made only for products which are, at the time of award of contract, qualified for inclusion in Qualified Manufacturers List (QML-19500) whether or not such products have actually been so listed by that date. The attention of the contractors is called to these requirements, and manufacturers are urged to arrange to have the products that they propose to offer to the Federal Government tested for qualification in order that they may be eligible to be awarded contracts or orders for the products covered by this specification. Information pertaining to qualification of products may be obtained from DLA Land and Maritime, ATTN: VQE, P.O. Box 3990, Columbus, OH 43218-3990 or e-mail <u>vqe.chief@dla.mil</u>. An online listing of products qualified to this specification may be found in the Qualified Products Database (QPD) at https://gpldocs.dla.mil.
- * 6.4 PIN construction example.
- * 6.4.1 Encapsulated devices The PINs for encapsulated devices are constructed using the following form.



* 6.5 List of PINs.

* 6.5.1 <u>PINs for encapsulated devices</u>. The following is a list of possible PINs for encapsulated devices available on this specification sheet.

PII	Ns for type 2N5010, 2N5011,	2N5012, 2N5013, 2N5014, a	nd 2N5015
JAN2N5010	JANTX2N5010	JANTXV2N5010	JANS2N5010
JAN2N5010S	JANTX2N5010S	JANTXV2N5010S	JANS2N5010S
JAN2N5010U4	JANTX2N5010U4	JANTXV2N5010U4	JANS2N5010U4
JAN2N5011	JANTX2N5011	JANTXV2N5011	JANS2N5011
JAN2N5011S	JANTX2N5011S	JANTXV2N5011S	JANS2N5011S
JAN2N5011U4	JANTX2N5011U4	JANTXV2N5011U4	JANS2N5011U4
JAN2N5012	JANTX2N5012	JANTXV2N5012	JANS2N5012
JAN2N5012S	JANTX2N5012S	JANTXV2N5012S	JANS2N5012S
JAN2N5012U4	JANTX2N5012U4	JANTXV2N5012U4	JANS2N5012U4
JAN2N5013	JANTX2N5013	JANTXV2N5013	JANS2N5013
JAN2N5013S	JANTX2N5013S	JANTXV2N5013S	JANS2N5013S
JAN2N5013U4	JANTX2N5013U4	JANTXV2N5013U4	JANS2N5013U4
JAN2N5014	JANTX2N5014	JANTXV2N5014	JANS2N5014
JAN2N5014S	JANTX2N5014S	JANTXV2N5014S	JANS2N5014S
JAN2N5014U4	JANTX2N5014U4	JANTXV2N5014U4	JANS2N5014U4
JAN2N5015	JANTX2N5015	JANTXV2N5015	JANS2N5010
JAN2N5015S	JANTX2N5015S	JANTXV2N5015S	JANS2N5010S
JAN2N5015U4	JANTX2N5015U4	JANTXV2N5015U4	JANS2N5015U4

6.6 <u>Changes from previous issue</u>. The margins of this specification are marked with asterisks to indicate where changes from the previous issue were made. This was done as a convenience only and the Government assumes no liability whatsoever for any inaccuracies in these notations. Bidders and contractors are cautioned to evaluate the requirements of this document based on the entire content irrespective of the marginal notations and relationship to the previous issue.

Preparing activity:

(Project 5961-2019-119)

DLA - CC

Custodians:

Army - CR

Navy - EC

Air Force - 85

NASA - NA

DLA - CC

Review activities:

Army - AR, MI, SM

Navy - AS, MC

* Air Force - 19, 71

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